Supporting Information

Key Role of d^0 and d^{10} Cations for the Design of Semiconducting Colusites: Large Thermoelectric *ZT* in Cu₂₆Ti₂Sb₆S₃₂ compounds

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Table S1. Hubbard U(eV) correction computed with the ACBN0 approach.

Ti	Cu (12f)	Cu (6d)	Cu (8e)	Sb	S (24i)	S (8e)	Ge
0.009	7.995	7.565	7.780	0.005	1.483	1.643	0.003



Figure S1. Rietveld refinements of powder X-ray diffraction patterns recorded at room temperature of: a) Cu₂₆Ti₂Sb₆S₃₂ ($R_{Bragg} = 4.27$, $R_F = 9.29$, $R_{wp} = 4.67$, $R_{exp} = 5.97$, $\chi^2 = 0.612$), b) Cu₂₆Ti₂Sb₅GeS₃₂ ($R_{Bragg} = 1.71$, $R_F = 3.54$, $R_{wp} = 4.10$, $R_{exp} = 5.78$, $\chi^2 = 0.503$), c) Cu₂₆Ti₂Sb₄Ge₂S₃₂ ($R_{Bragg} = 2.51$, $R_F = 4.23$, $R_{wp} = 4.11$, $R_{exp} = 5.75$, $\chi^2 = 0.510$), and d) Cu₂₆Ti₂Sb₃Ge₃S₃₂ ($R_{Bragg} = 1.80$, $R_F = 3.60$, $R_{wp} = 3.93$, $R_{exp} = 5.47$, $\chi^2 = 0.517$).

Atom	site	x	у	Z	$B_{\rm iso}$			
Ti	2a	0	0	0	1.03(29)			
Sb	6c	1/4	1/2	0	0.80(6)			
Cu	6d	1/4	0	1/2	1.80(14)			
Cu	8e	0.246(1)	x	x	1.16(14)			
Cu	12f	0.256(1)	0	0	0.93(10)			
S	8e	0.122(1)	x	x	-0.28(46)			
S	24i	0.377(1)	0.366(1)	0.132(1)	0.59(20)			
$Cu_{26}T_2$	M_6S_{32}		$T = \mathrm{Ti},$	T = V,	T = V,	T = W,	T = Mo,	T = Cr,
Distanc	es		M = Sb	M = Sn	M = Ge	M = Ge	M = Ge	M = Ge
<i>T</i> (2a)-S	(8e) ×4		2.271 Å	2.390 Å	2.247 Å	2.343 Å	2.351 Å	2.218 Å
<i>T</i> (2a)-C	Cu(12f)	×6	2.763 Å	2.736 Å	2.739 Å	2.763 Å	2.752 Å	2.709 Å
M(6c)-5	S(24i) >	4	2.451 Å	2.422 Å	2.248 Å	2.213 Å	2.229 Å	2.230 Å
Cu(6d)	-S(24i)	$\times 4$	2.313 Å	2.254 Å	2.287 Å	2.313 Å	2.291 Å	2.291Å
Cu(8e)-	-S(8e) >	<1	2.327 Å	2.357 Å	2.376 Å	2.407 Å	2.332 Å	2.365 Å
Cu(8e)-	-S(24i)	×3	2.276 Å	2.277 Å	2.272 Å	2.273 Å	2.280 Å	2.271 Å
Cu(12f)-S(8e) ×2		2.355 Å	2.377 Å	2.333 Å	2.377 Å	2.373 Å	2.307 Å	
Cu(12f)-S(24i) ×2		2.297 Å	2.330 Å	2.298 Å	2.288 Å	2.295 Å	2.306 Å	
Average	Average Cu-S		2.309 Å	2.302 Å	2.300 Å	2.317 Å	2.306 Å	2.297 Å

Table S2. Rietveld refinement result for powder X-ray diffraction pattern of $Cu_{26}Ti_2Sb_6S_{32}$. The interatomic distances of $Cu_{26}Ti_2Sb_6S_{32}$ are compared with those of $Cu_{26}V_2Sn_6S_{32}^{S1}$ and $Cu_{26}T_2Ge_6S_{32}$ (T = Cr, Mo, W)^{S2} colusites.

(S1) Bourgès, C.; Bouyrie, Y.; Supka, A. R.; Al Rahal Al Orabi, R.; Lemoine, P.; Lebedev, O. I.; Ohta,
M.; Suekuni, K.; Nassif, V.; Hardy, V.; Daou, R.; Miyazaki, Y.; Fornari, M.; Guilmeau, E. High-Performance Thermoelectric Bulk Colusite by Process Controlled Structural Disordering. *J. Am. Chem.* Soc. 2018, 140, 2186–2195.

(S2) Pavan Kumar, V.; Supka, A. R.; Lemoine, P.; Lebedev, O. I.; Raveau, B.; Suekuni, K.; Nassif, V.; Al Rahal Al Orabi, R.; Fornari, M.; Guilmeau, E. High Power Factors of Thermoelectric Colusites $Cu_{26}T_2Ge_6S_{32}$ (T = V, Cr, Mo, W): Toward Functionalization of the Conductive "Cu–S" Network. *Adv. Energy Mater.* **2019**, 9, 1803249.

Table S3. Chemical compositions for the sintered samples of $Cu_{26}Ti_2Sb_{6-x}Ge_xS_{32}$. The standard deviation of the composition is given in the parentheses. As known for all sulfides, the determination of the sulfur content by EDS is not accurate. Thus, the value of about 29 S is in the limit of the experimental errors that can be estimated to ~10% with respect to 32 S determined from the structural analysis. Consequently, the "observed" S deficiency cannot be considered as significant and moreover is inconsistent with the p-type semiconducting behavior of $Cu_{26}Ti_2Sb_6S_{32}$.

	Cu	Ti	Sb	Ge	S
x = 0	25.9(2)	1.9(1)	6.2(2)	—	29.5(5)
x = 1	26.0(3)	1.9(1)	5.2(2)	0.9(3)	29.4(5)
x = 2	26.1(4)	1.9(2)	4.2(3)	1.8(4)	29.4(6)
x = 3	26.3(3)	1.9(1)	3.1(1)	2.7(3)	29.5(4)



Figure S2. Elemental mapping of energy dispersive spectroscopy for $Cu_{26}Ti_2Sb_{6-x}Ge_xS_{32}$ (x = 2).



Figure S3. Scanning electron microscope images for $Cu_{26}Ti_2Sb_{6-x}Ge_xS_{32}$ (x = 0-3).



Figure S4. (a) Electrical resistivity ρ and (b) Seebeck coefficient S for Cu₂₆Ti₂Sb_{6-x}Ge_xS₃₂ (x = 0).



Figure S5. Electronic density of states of $Cu_{26}Ti_2Sb_{6-x}Ge_xS_{32}$ (x = 0-3).



Figure S6. Electrical resistivity ρ and Seebeck coefficient *S* of Cu₂₆Ti₂Sb_{6-x}Ge_xS₃₂ (x = 0-3) calculated based on the electronic structure (Figure 3 in the main text and Figure S5).



Figure S7. (a) Electrical resistivity ρ , (b) hole carrier concentration *n*, and (c, d) Hall mobility $\mu_{\rm H}$ for Cu₂₆Ti₂Sb_{6-x}Ge_xS₃₂ (x = 1-3). The data $\mu_{\rm H}$ fall on a $\propto T^{-3/2}$ line.



Figure S8. Powder X-ray diffraction patterns for $Cu_{26}Ti_2Sb_{6-x}Ge_xS_{32}$ (x = 0). After the measurement of the electrical resistivity ρ and Seebeck coefficient *S* (Figure S4), $Cu_{12}Sb_4S_{13}$ and an unknown phase appeared at a surface of the sample. The secondary phases can be removed by polishing. A calculated pattern for $Cu_{12}Sb_4S_{13}$ is also shown.



Figure S9. Powder X-ray diffraction patterns measured on the surface of Cu₂₆Ti₂Sb_{6-x}Ge_xS₃₂ (x = 0-3) samples after the measurement of the electrical resistivity ρ and Seebeck coefficient *S* (Figure 4).



Figure S10. Thermogravimetry/differential thermal analysis data for $Cu_{26}Ti_2Sb_{6-x}Ge_xS_{32}$ (x = 0, 2). Endothermic peaks accompanied by mass reduction were observed at around 850 K.



Figure S11. Mode-resolved Grüneisen parameters of Cu₂₆Ti₂Sb₆S₃₂ calculated based on the phonon structure (Figure 5 in the main text).